

Claim 19. (new)

A method according to claim 12 wherein said microorganism is Legionellae.

Claim 20. (new)

A method according to claim 12 wherein said microorganism is mold and mold spores.

Claim 21. (new)

A method according to claim 13 wherein said chlorine is present in said mixture of chlorine and argon in an amount of about 1.0 to 3% by partial pressure of the total mixture.

Claim 22. (new)

A method according to claim 13 wherein said chlorine is present in said mixture of chlorine and argon in an amount of 0.1% to 25% by partial pressure of the total mixture.

**Remarks**

The above claims are directed to the non-elected invention, which is removing microorganisms with a chlorine/noble gas mixture.

Consideration of the RCE application is respectfully requested.

Respectfully Submitted



Evelyn M. Sommer

Registration No. 19, 603

Attorney for Applicant

250 Park Avenue, Suite 825

New York, NY 10177

Phone: 212-527-2657

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